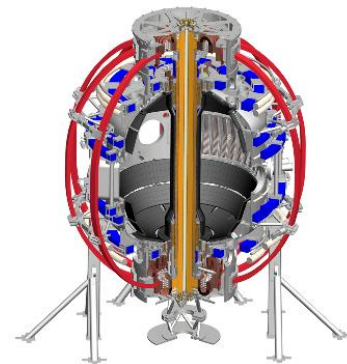


Effects of the H species in the HHFW performance in NSTX/NSTX-U

Nicola Bertelli

E.F. Jaeger (XCEL), R. W. Harvey (CompX), J.C. Hosea, E.-H. Kim,
R.J. Perkins, G. Taylor, and E.J. Valeo, (PPPL)

APS-DPP 2017



Abstract

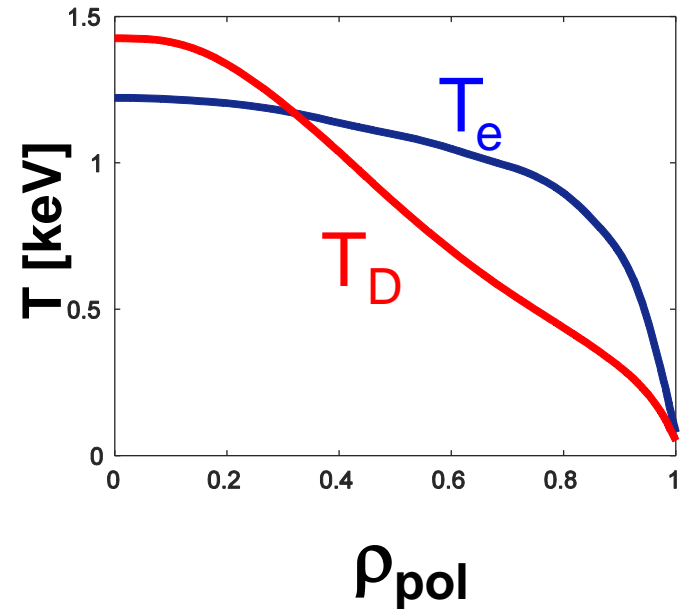
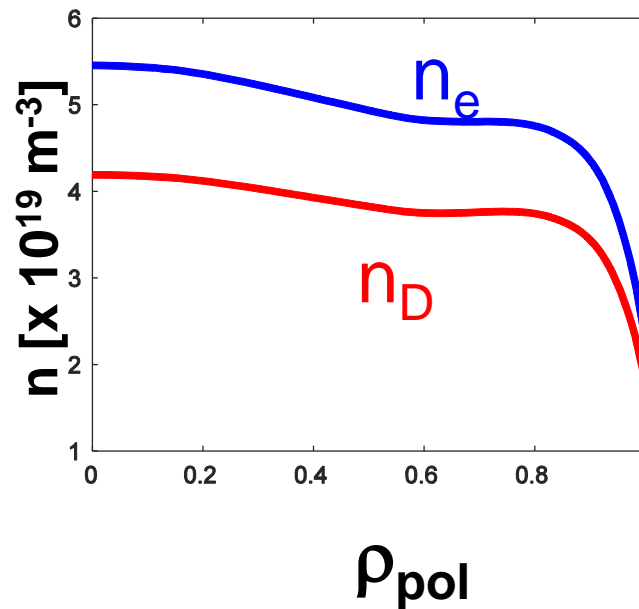
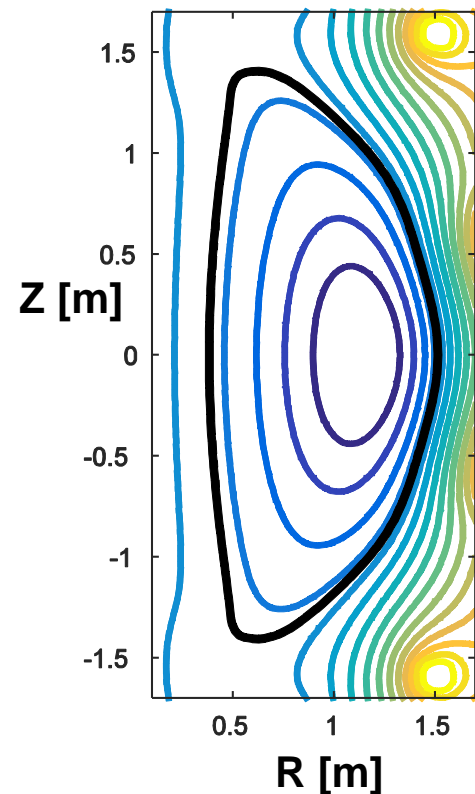
One of the goal of NSTX-U is to operate at full eld ($B = 1$ T). For this magnetic field, the first and second harmonics of hydrogen (H) are located at the high-field side and in the core plasma, respectively. In principle, part of the high-harmonic fast-wave (HHFW) injected power can be absorbed by the H population reducing the electron and/or the fast-ion heating. For this reason, full wave simulations results of NSTX-U scenarios with different H concentrations for wave frequencies of 30 and 60 MHz will be presented and discussed. Plasma scenarios with and without neutral beam injection (NBI) will be considered. Furthermore, the balance between the beam ion and electron power absorption will be analyzed comparing both NSTX and NSTX-U plasmas.

Outline

- NSTX-U “Scenarios” considered
- Antenna frequency = 30 MHz
 - H Concentration scan
 - w/ & w/o NBI
- Antenna frequency = 60 MHz
 - H concentration scan
 - w/ and w/o NBI

NSTX-U “Scenarios” considered (1)

- NSTX-U plasma
 - $B = 1\text{T}$
 - Ion species: D, H, C, D_{BEAM}



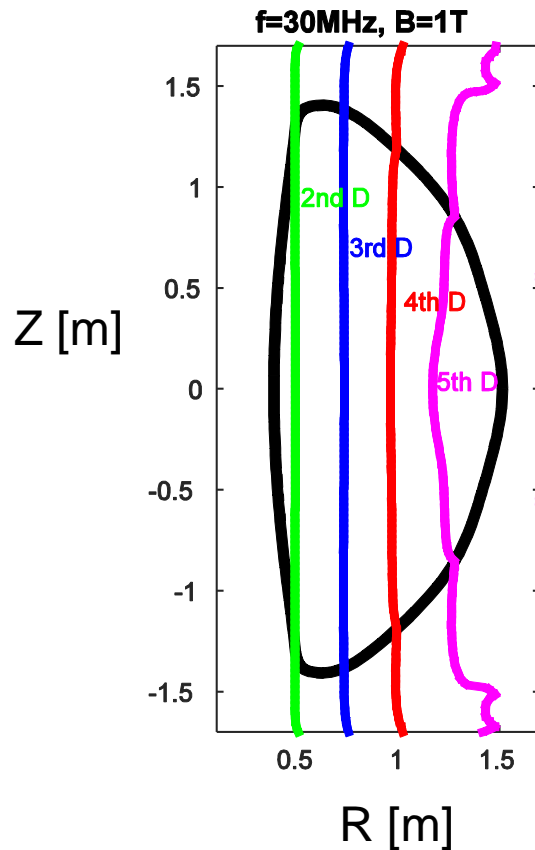
NSTX-U “Scenarios” considered (2)

- NSTX-U plasma
 - $B = 1\text{T}$
- H concentration scan:
 - $n_{\text{H}}/n_{\text{e}} = 1\%$
 - $n_{\text{H}}/n_{\text{e}} = 2\%$
 - $n_{\text{H}}/n_{\text{e}} = 5\%$
 - $n_{\text{H}}/n_{\text{e}} = 10\%$
- w/ and w/o NBI
- Two antenna frequencies
 - 30 MHz and 60 MHz
- Three n_{phi} values: -5, -12, -21
- Employed full wave code AORSA

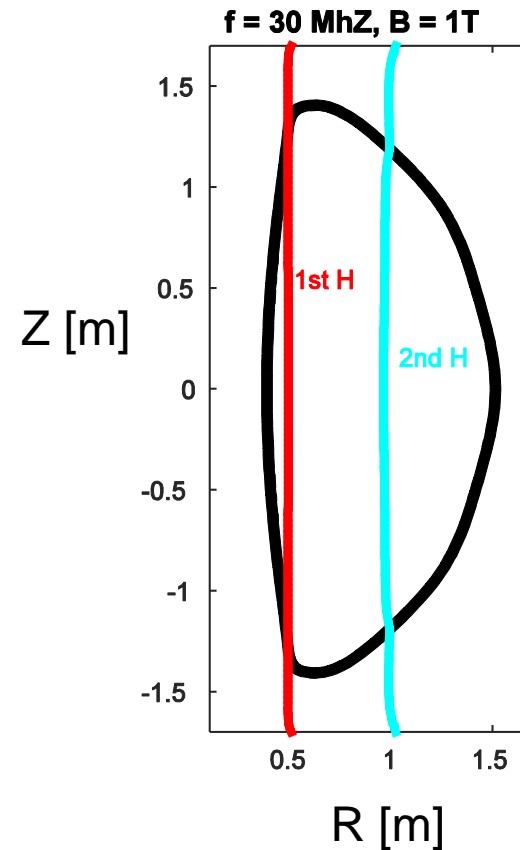
NSTX-U “Scenarios” considered (3)

- NSTX-U plasma: $B = 1\text{ T}$ and $f = 30\text{ MHz}$

D resonances



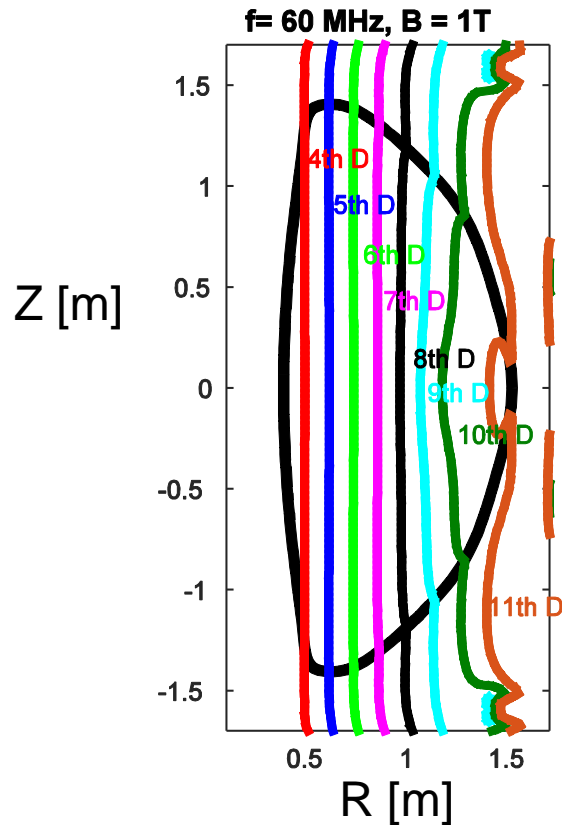
H resonances



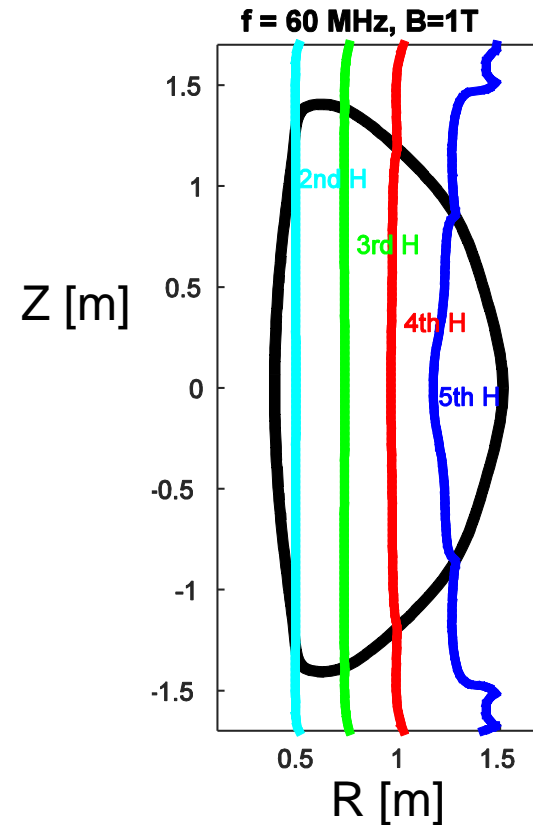
NSTX-U “Scenarios” considered (4)

- NSTX-U plasma: $B = 1\text{ T}$ and $f = 60\text{ MHz}$

D resonances

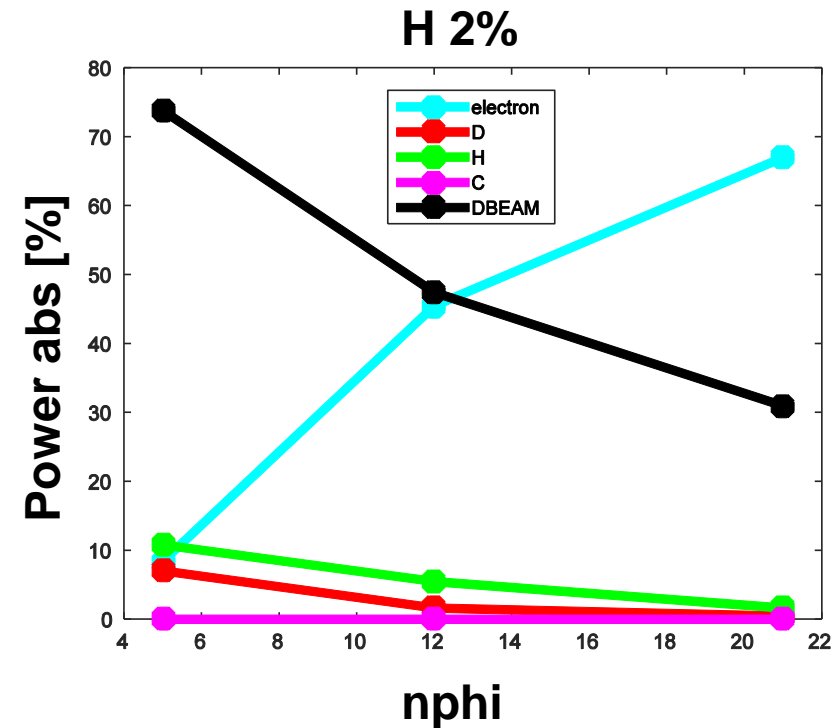
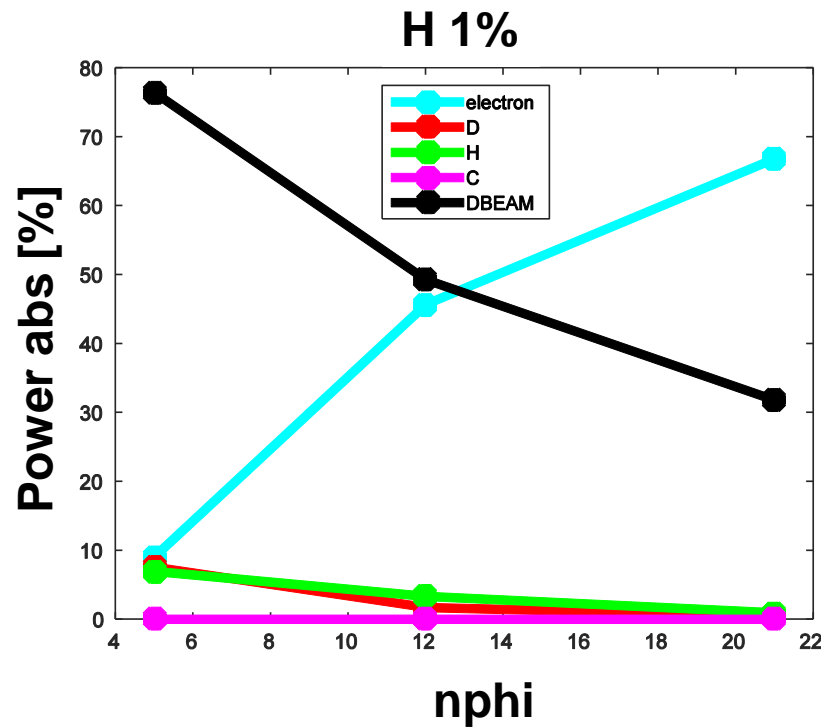


H resonances



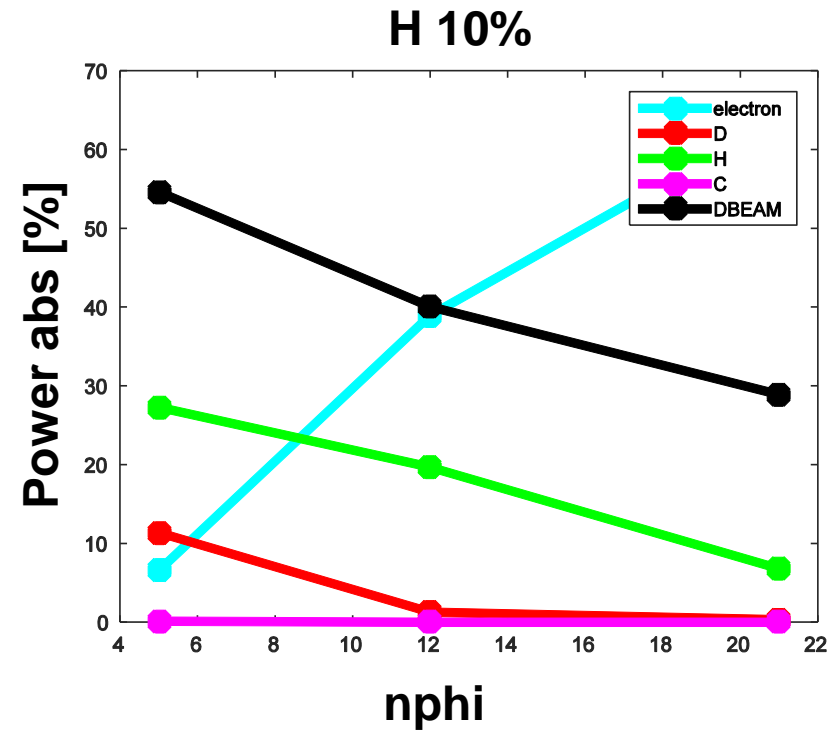
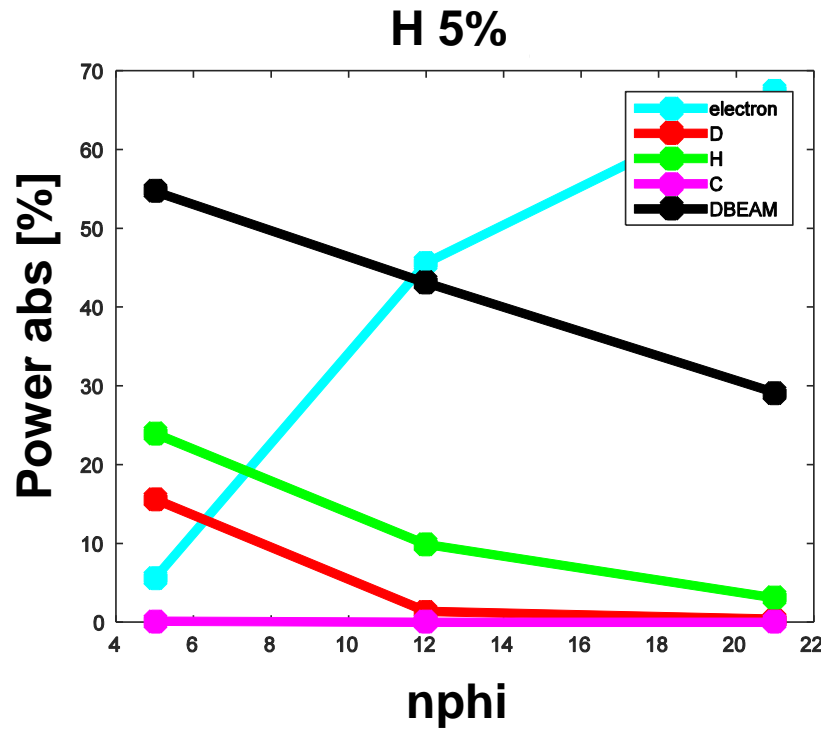
**f = 30 MHz, H 1%, 2%, 5% and 10%
with NBI**

Power absorption vs. toroidal wave number



- Electron absorption increases with larger $n\phi$
- (Fast) Ion abs. decreases with larger $n\phi$
- Not significant H power absorption for H 1% & 2%

Power absorption vs. toroidal wave number

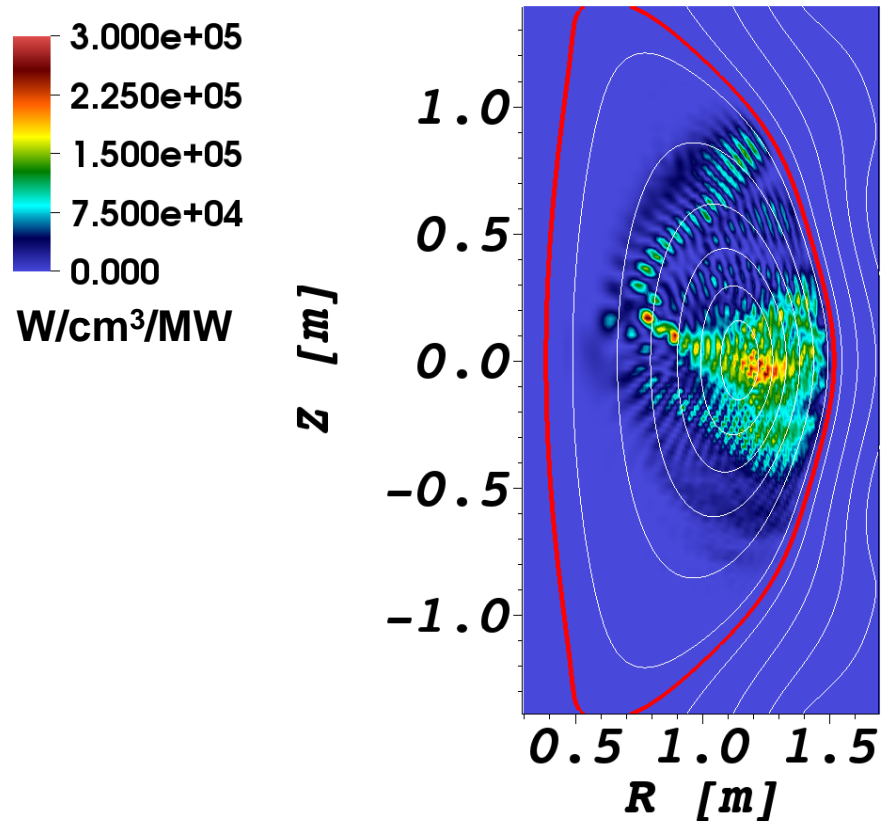


- Not significant H power absorption for 5%
 - except for $nphi = |5|$ & H 10% and $nphi = -5$)
- The “heating phase” ($nphi = |21|$) is quite good for electron absorption

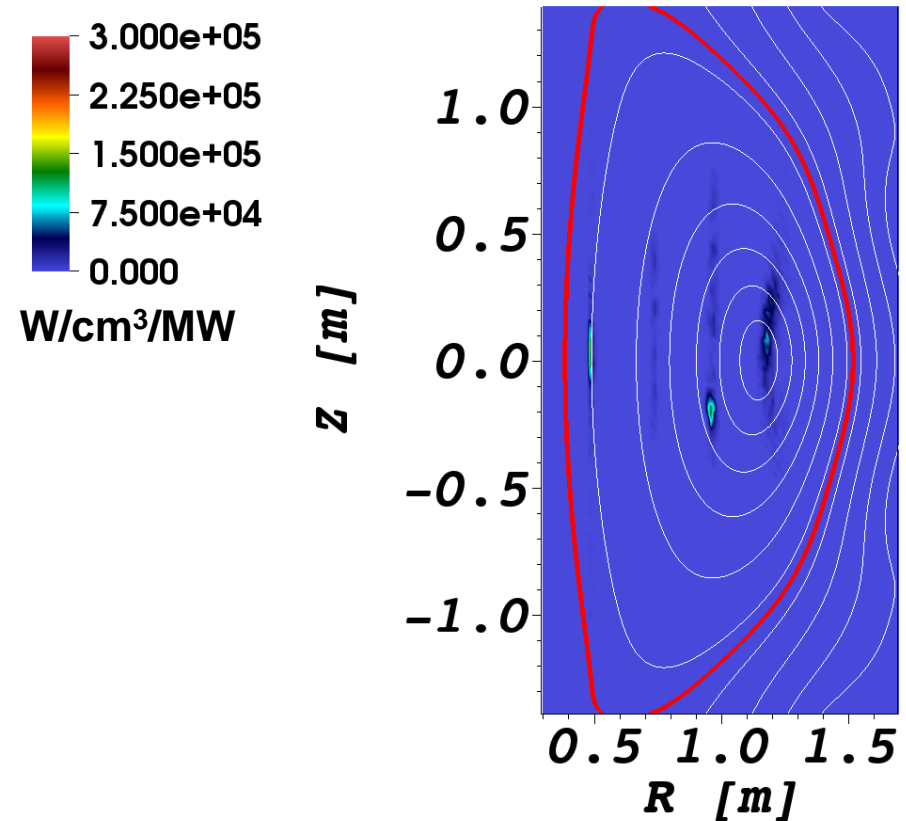
2D Power deposition profiles (1)

10% H concentration case & $n_{\text{phi}} = -12$

Electron power deposition



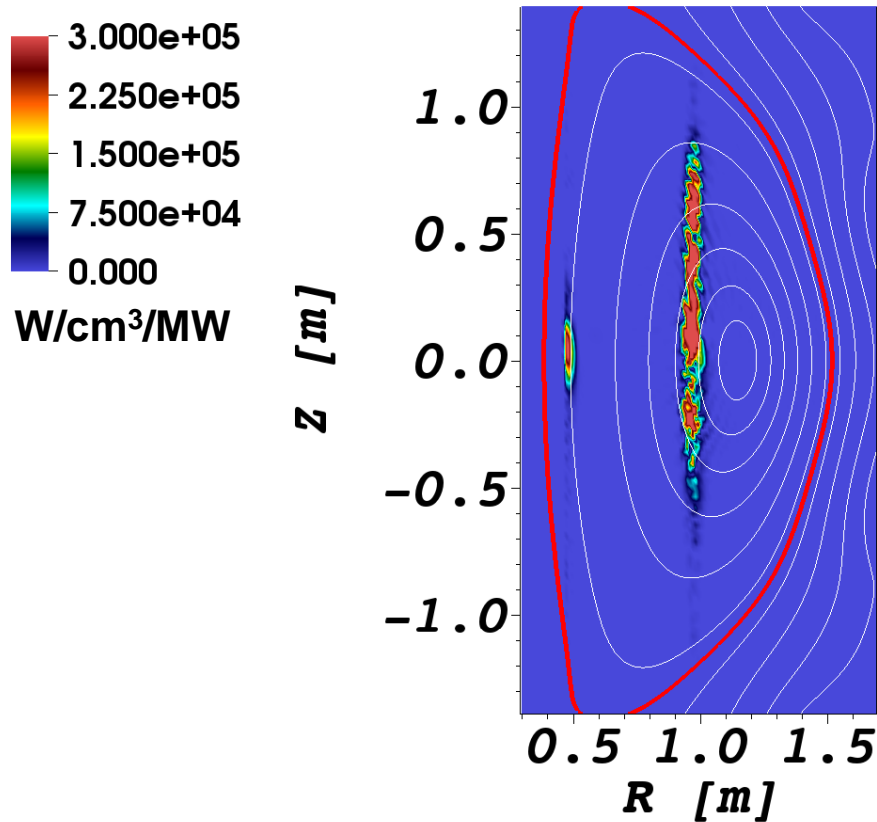
D thermal power deposition



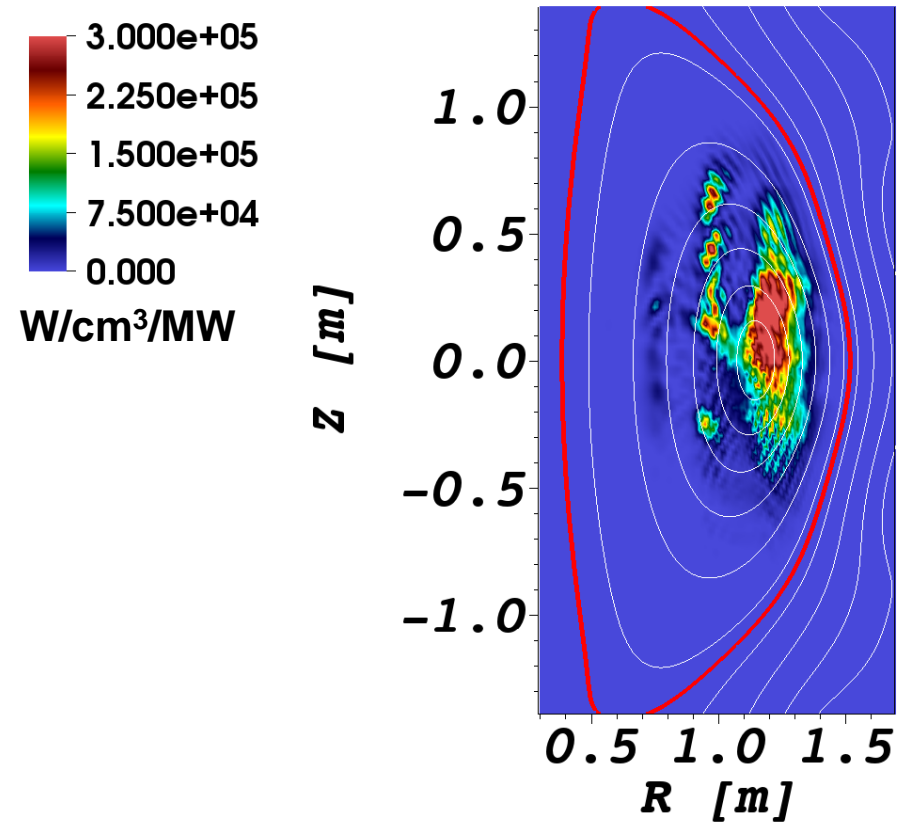
2D Power deposition profiles (2)

10% H concentration case & $n_{\text{phi}} = -12$

H power deposition



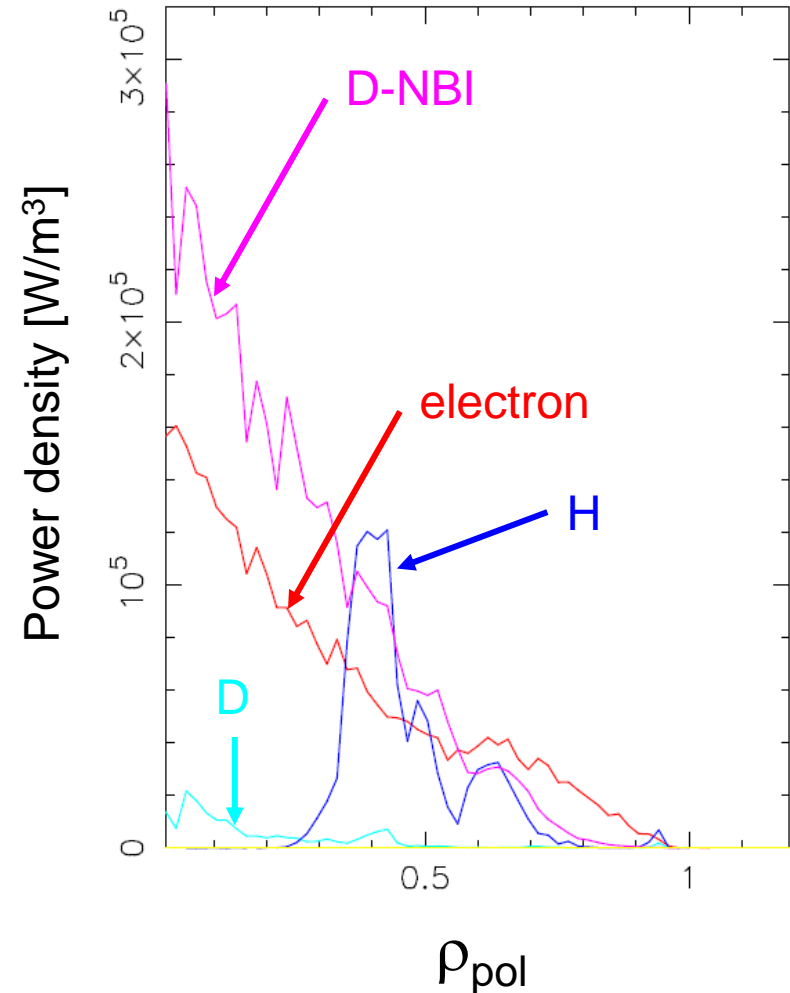
D-NBI power deposition



Flux surface avg deposition profiles

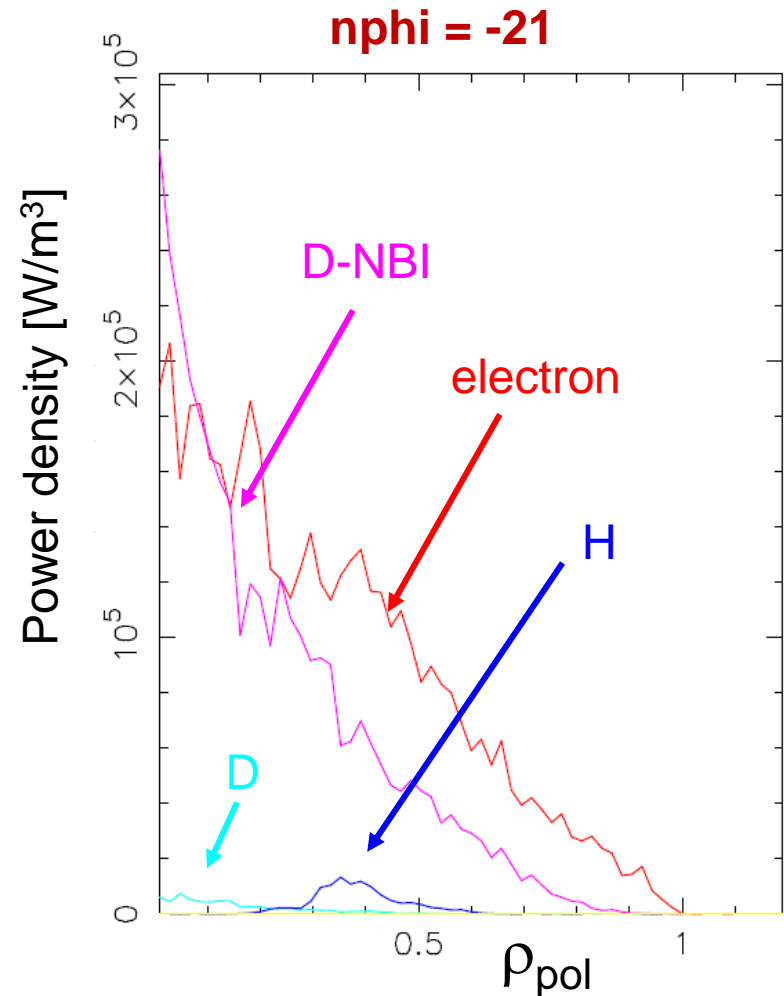
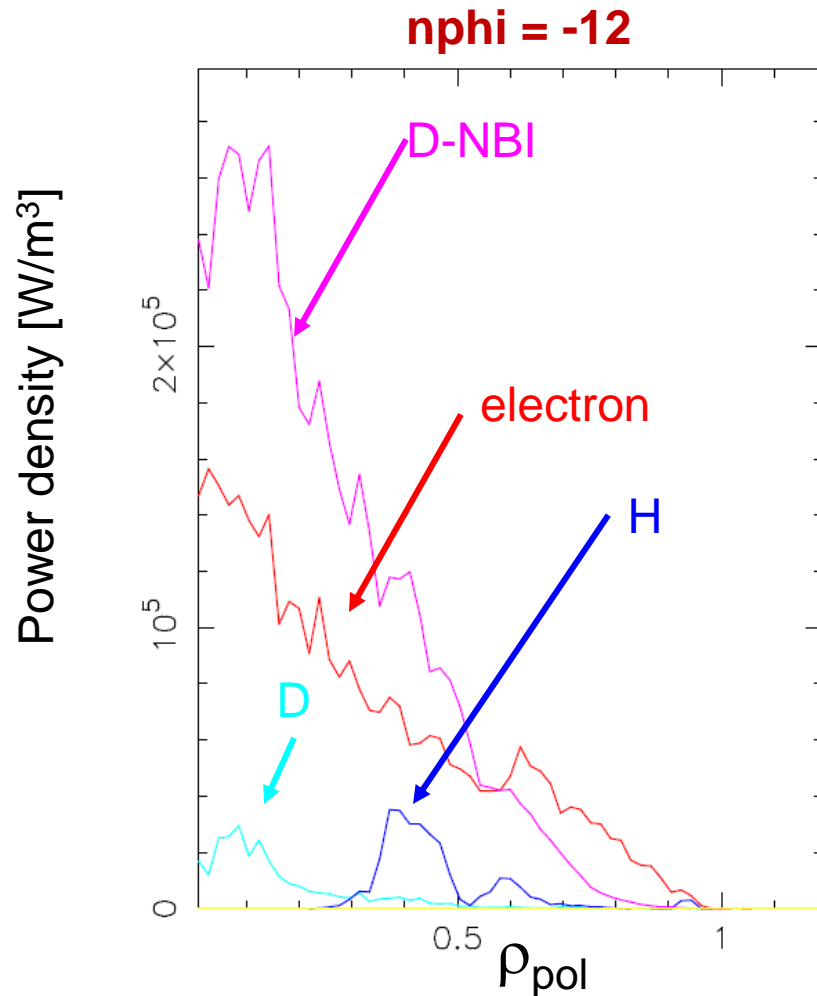
10% H concentration case & $n_{phi} = -12$

- Electron & D-NBI power depositions peaked on axis
- H power deposition localized on 2nd H resonance
- Thermal D & C are basically negligible



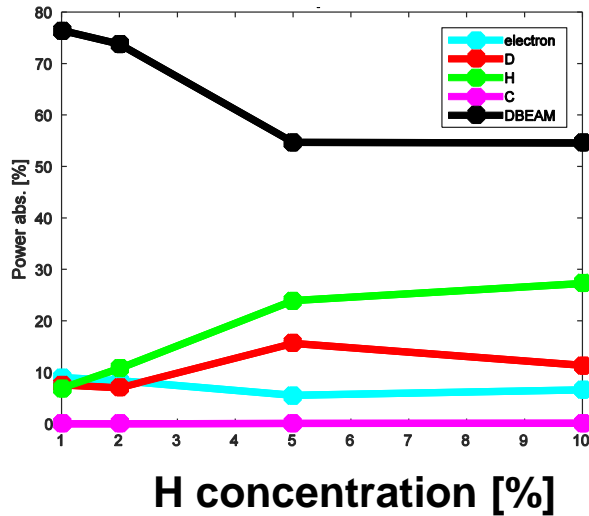
Flux surface avg. deposition profiles

2% H concentration

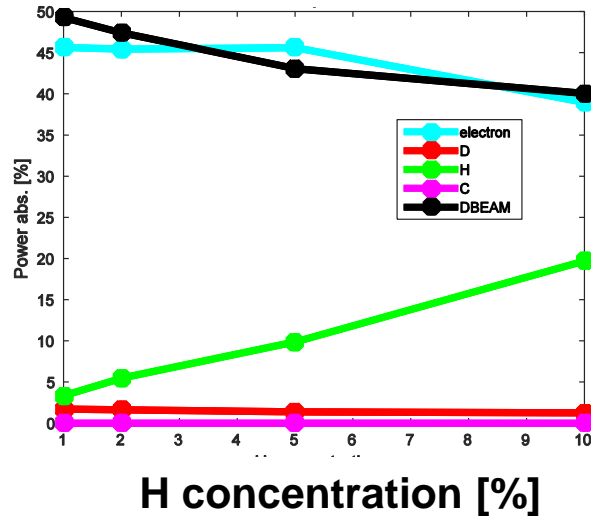


Power absorption vs. H concentration

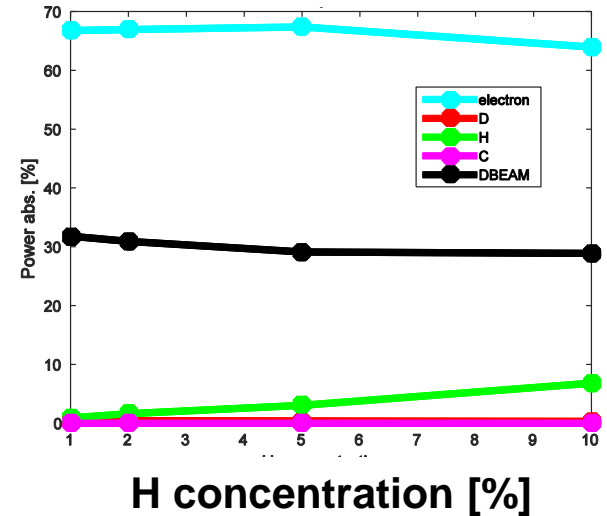
$n_{phi} = -5$



$n_{phi} = -12$



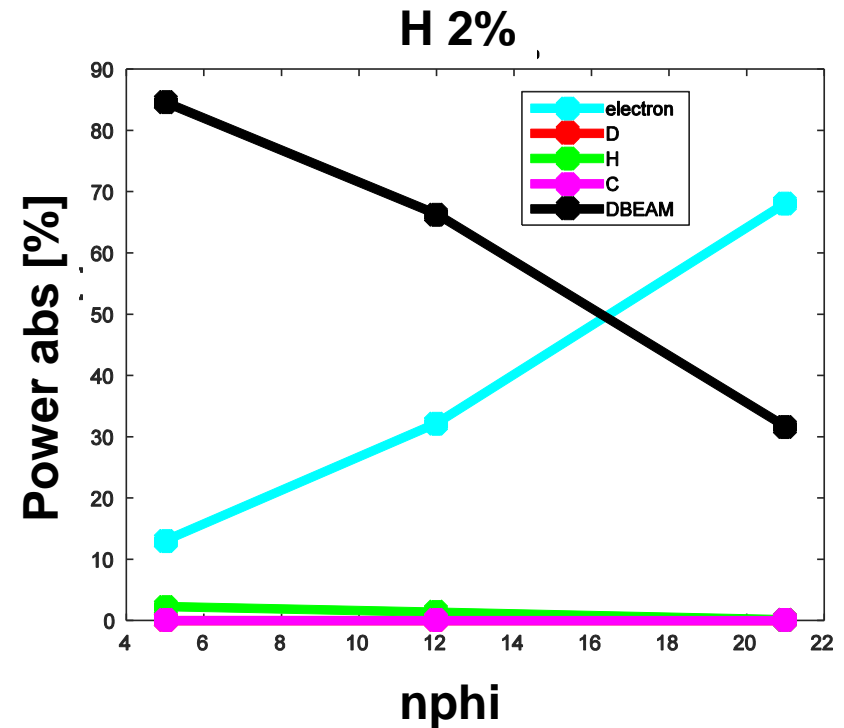
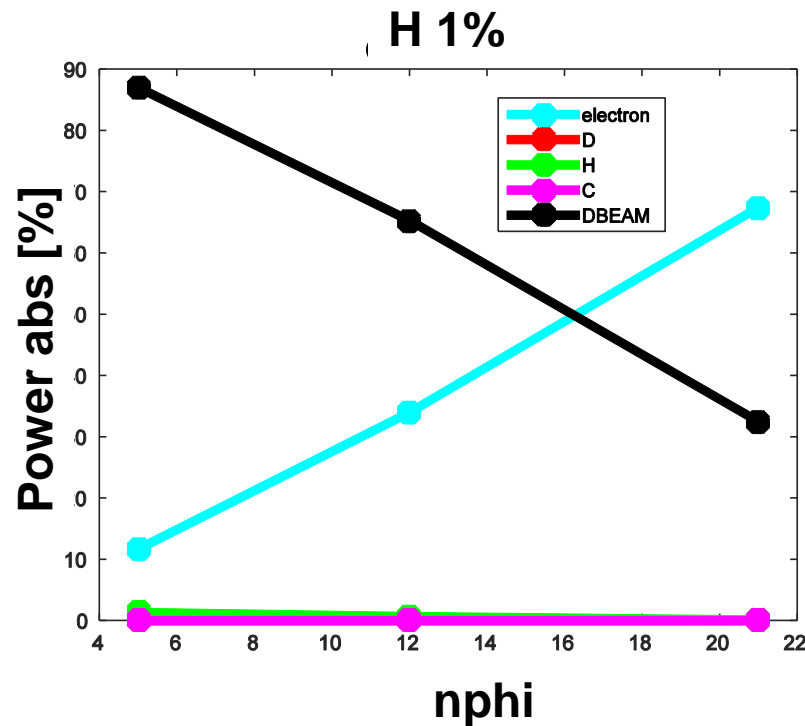
$n_{phi} = -21$



- H power absorption increases with larger H concentration and decreases for larger n_{phi}
- In general, no significant impact by H concentration
 - $n_{phi} = -21$ case is basically independent from H concentration

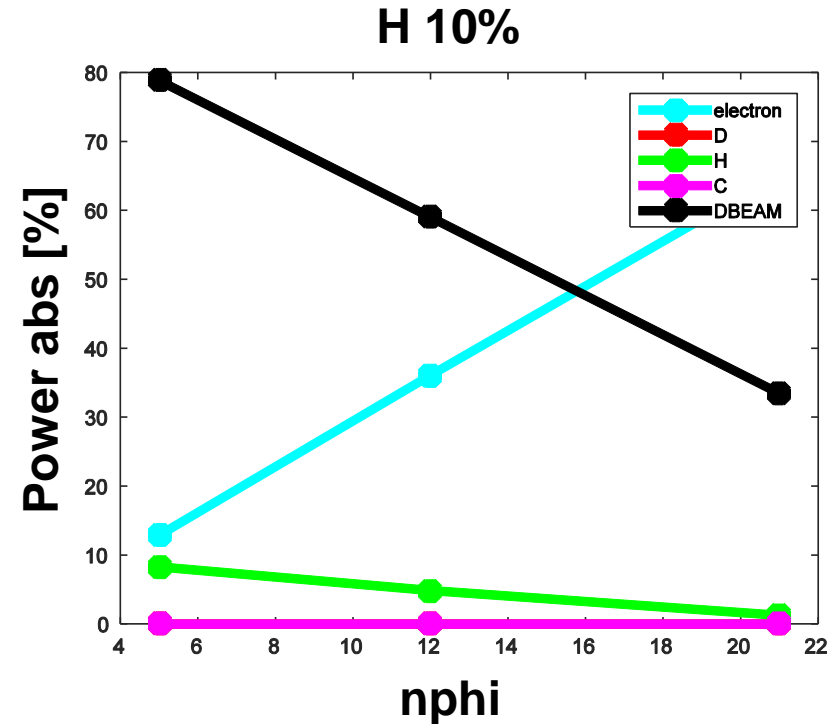
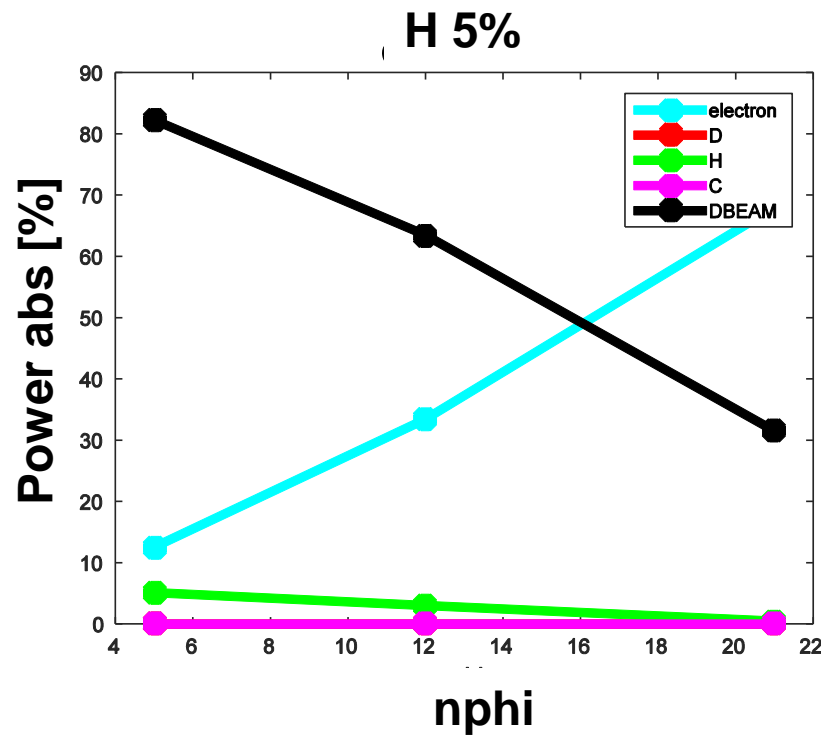
**f = 60 MHz, H 1%, 2%, 5% and 10%
with NBI**

Power absorption vs. nphi



- Similar conclusions as $f=30$ MHz case
 - Electron absorption increases with larger nphi
 - (Fast) Ion absorption decreases with larger nphi

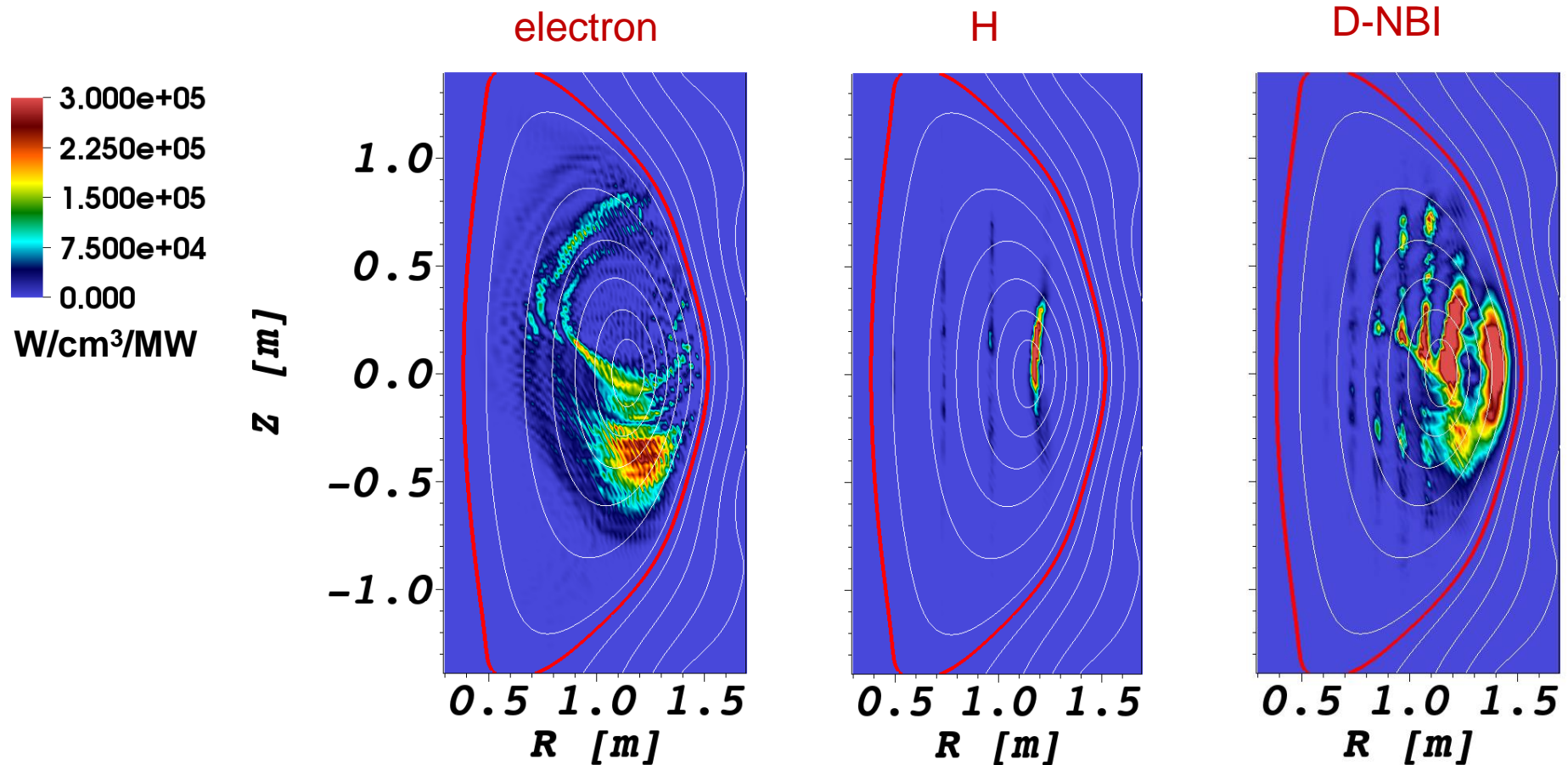
Power absorption vs. nphi



- H abs. increases with larger H concentration
- nphi = -21 (“heating phase”) is quite good for electron abs.
- No D & C contributions

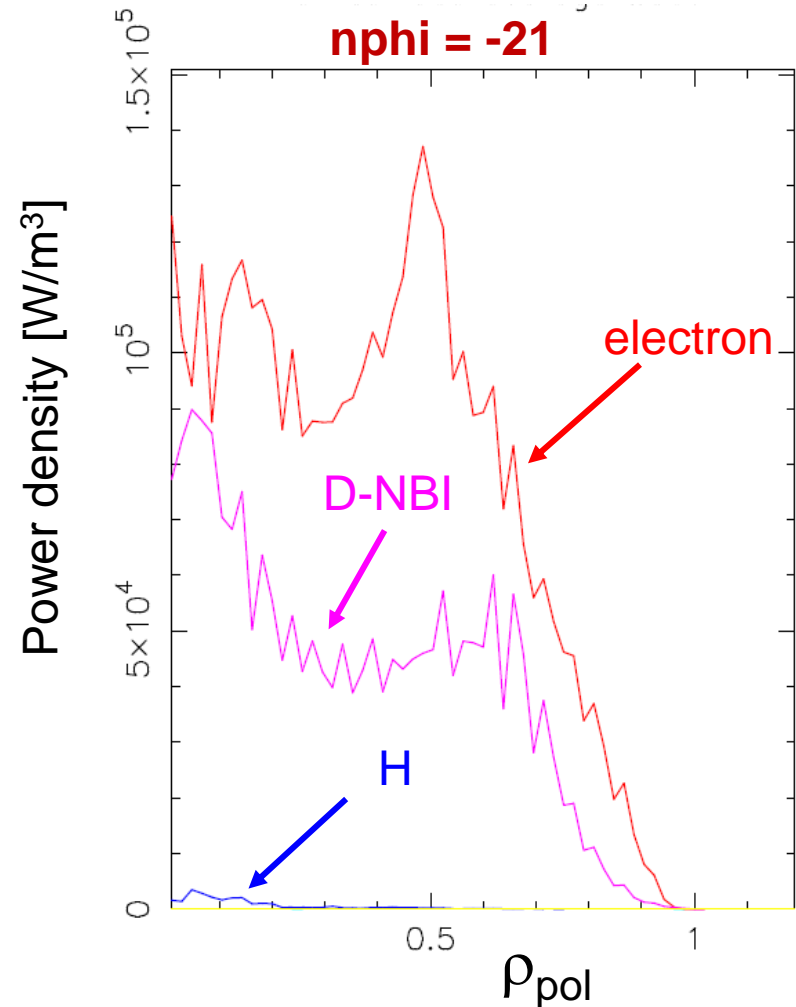
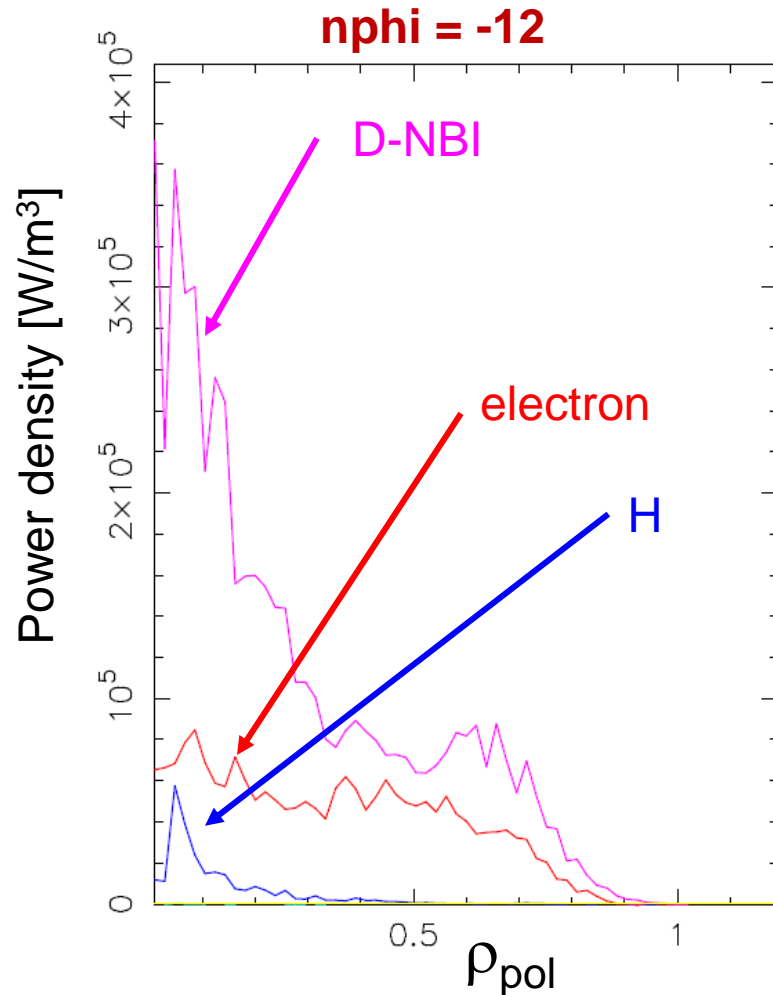
2D Power deposition profiles (1)

10% H concentration case & $n_{\text{phi}} = -12$

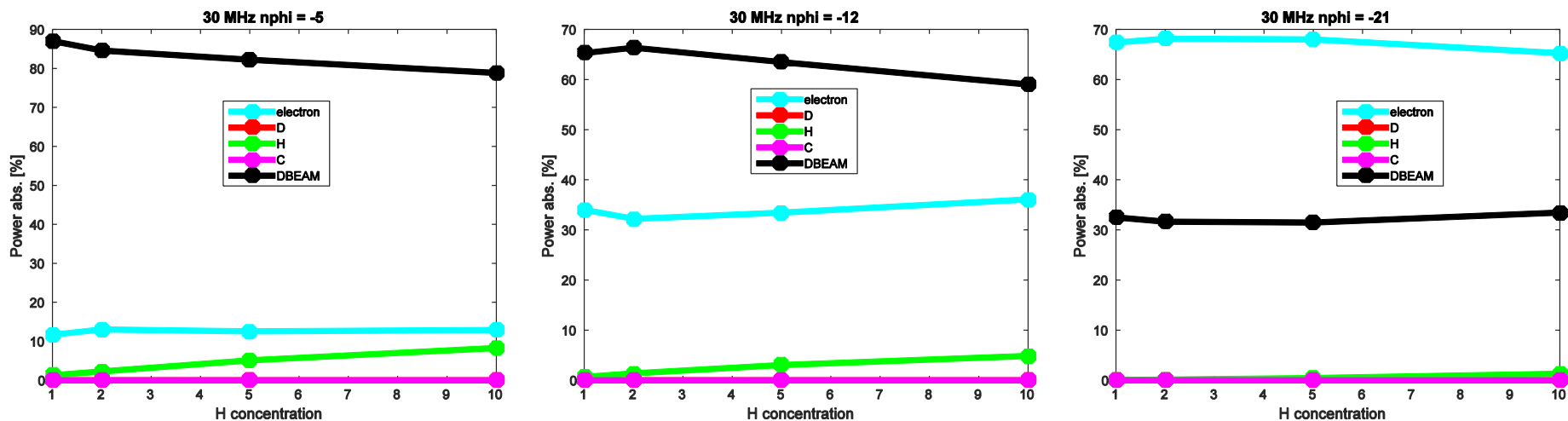


Flux surface avg. deposition profiles

2% H concentration



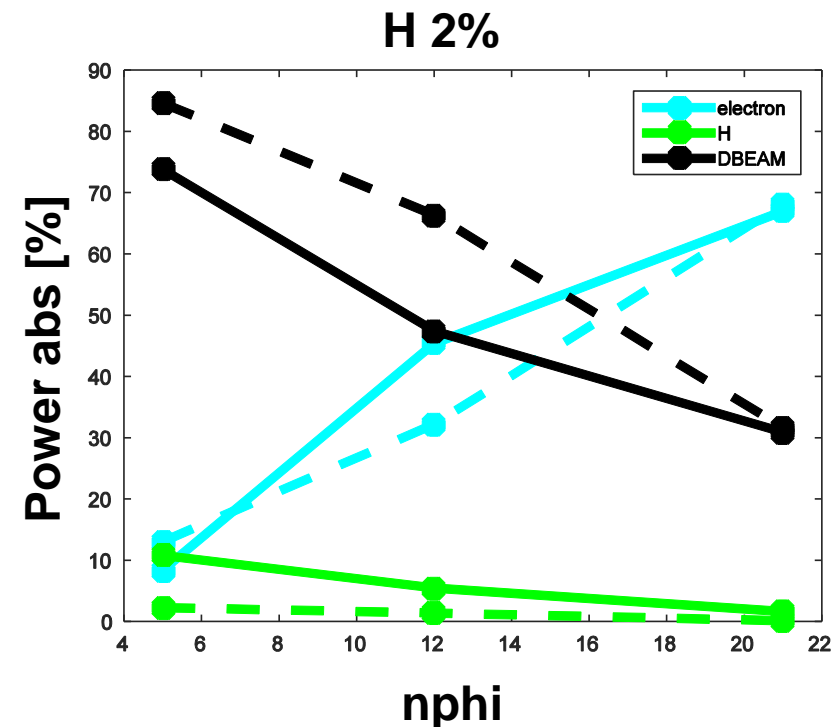
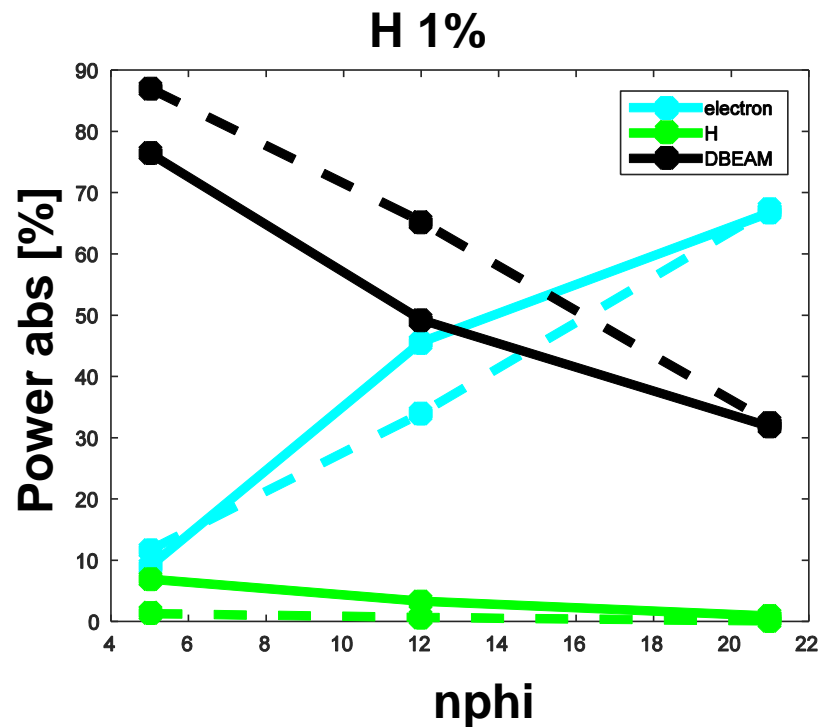
Power abs. vs. H concentration



- H abs increases with larger H concentration and decreases for larger n_{phi}
- Power abs. is almost independent from H concentration

Comparison between $f = 30$ and 60 MHz H 1%, 2%, 5% and 10% with NBI

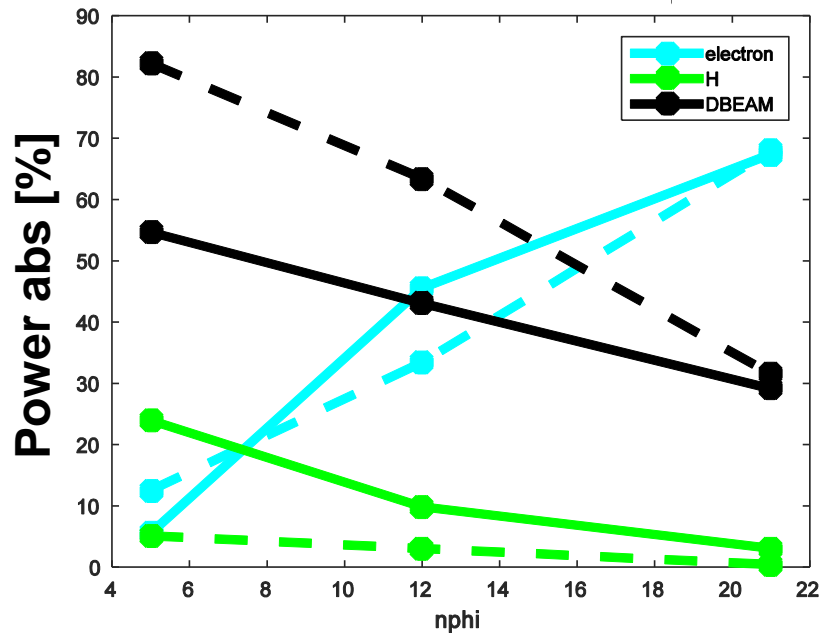
Power absorption vs. n_{phi} ($f = 30\text{MHz}$ solid, $f = 60\text{MHz}$ dashed curves)



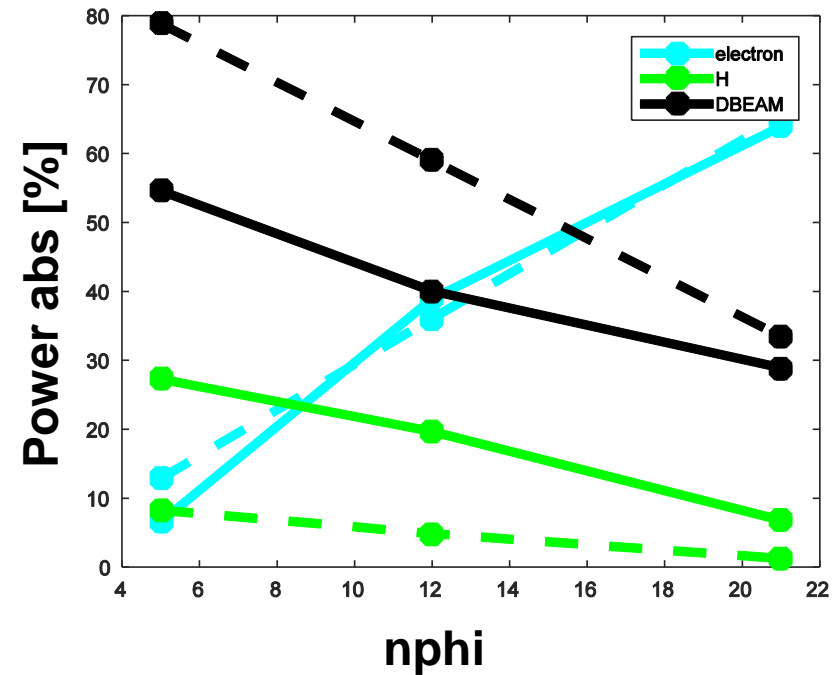
- 60 MHz case has higher fast ion abs. than 30 MHz case for $n_{phi} = -5$ and -12
- For $n_{phi} = -21$, power abs. very similar between two cases

Power abs. vs. nphi (f = 30MHz solid, f = 60MHz dashed curves)

H 5%



H 10%



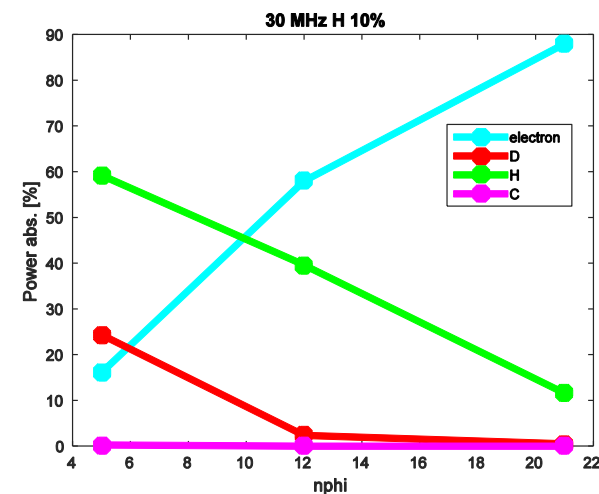
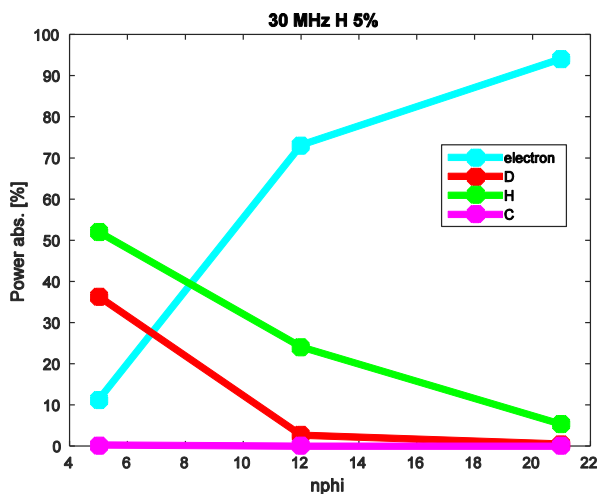
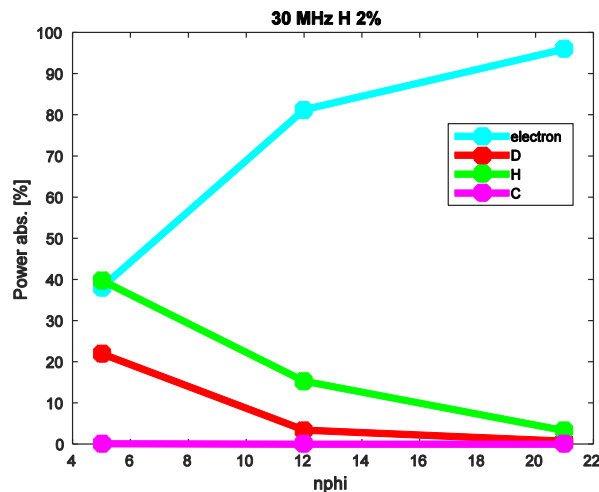
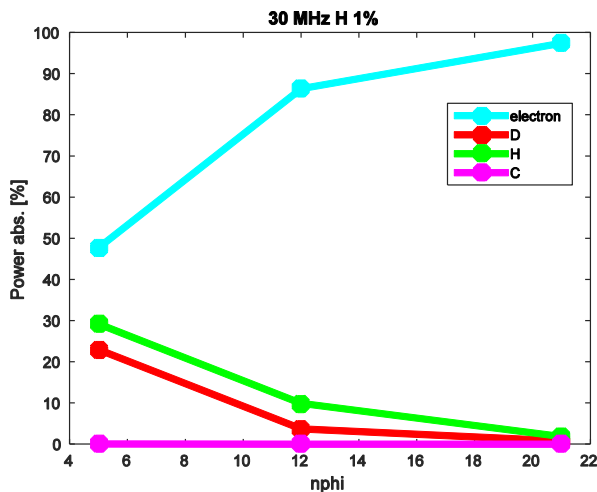
- Small H power absorption except for 10% concentration and lower $n\phi$

Conclusions for $f = 30$ and 60 MHz with NBI

- Current drive phase (i.e, $n\phi_i = -5$) it seems to be bad
- Large electron damping for $n\phi_i = -21$ (i.e. heating phase)
 - however, ~30% of power to fast ions
 - NO significant differences between $f = 30$ and 60 MHz
- For $n\phi_i = -5$ and -12 , higher fast ions abs. for 60 MHz case than 30MHz case
- H absorption is significant (~10-30%) at low $n\phi_i$ and high H concentration (> 5%)
- In principle, HHFW might modify either the electron or the ion temperature (through H species)
 - Could be interesting for transport studies
 - See cases without NBI below

**f = 30 MHz, H 1%, 2%, 5% and 10%
NO NBI**

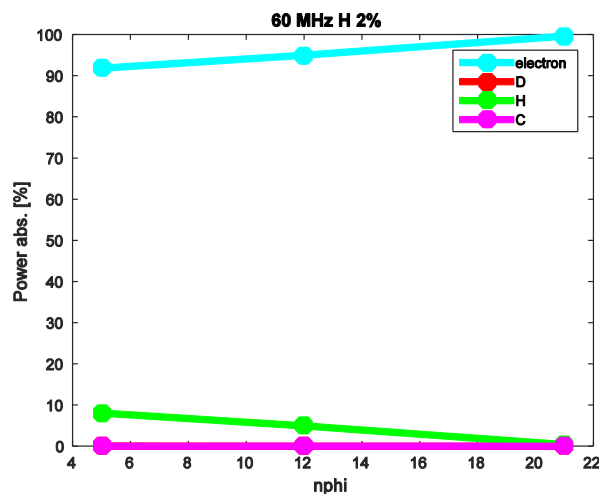
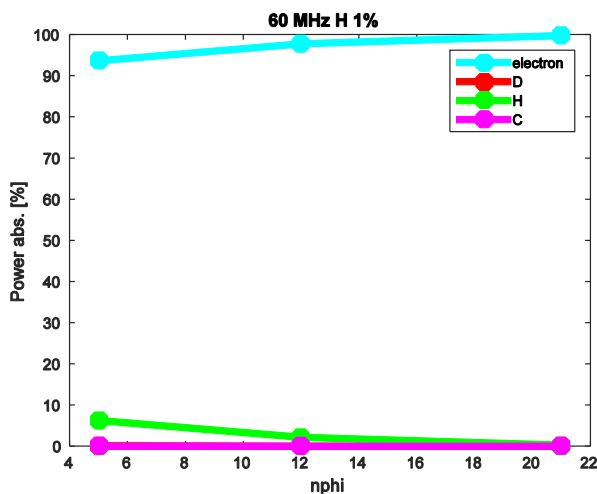
Power absorption vs. nphi



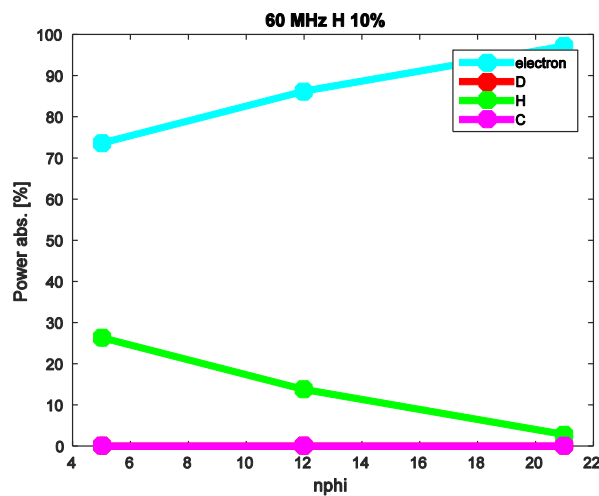
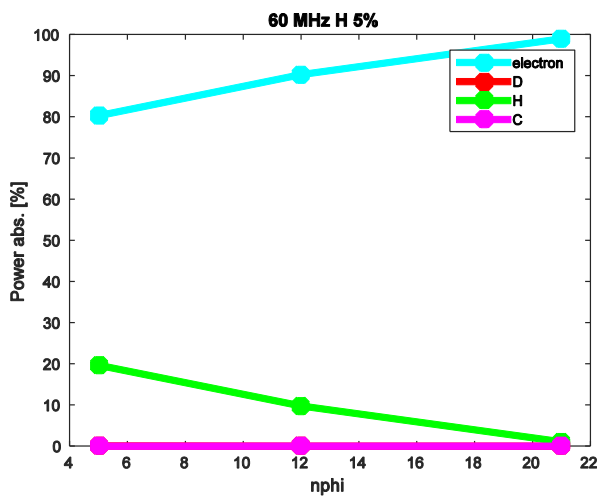
- For nphi = -12 and -21:
dominant electron abs.
– Except for H 10%
- Larger H absorption
for higher H concentration
- Possible H ions
acceleration due to HHFW

**f = 60 MHz, H 1%, 2%, 5% and 10%
NO NBI**

Power absorption vs. nphi



- Dominant electron abs. for all cases

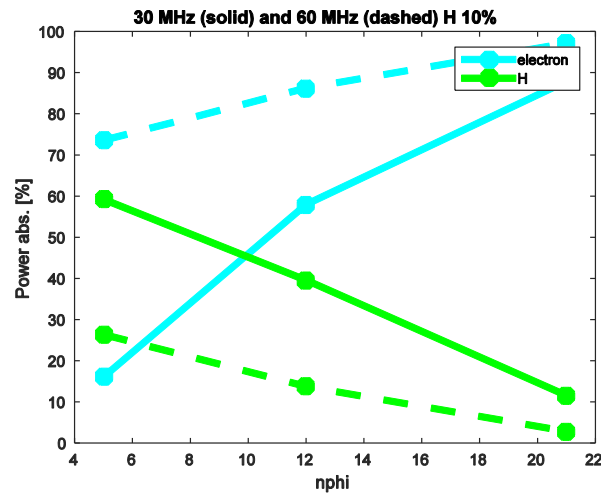
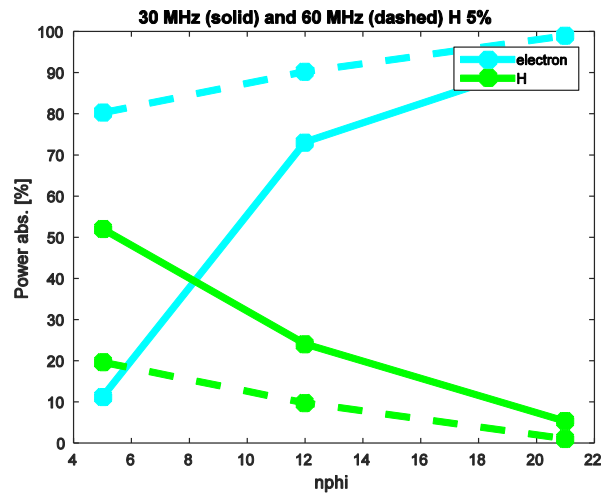
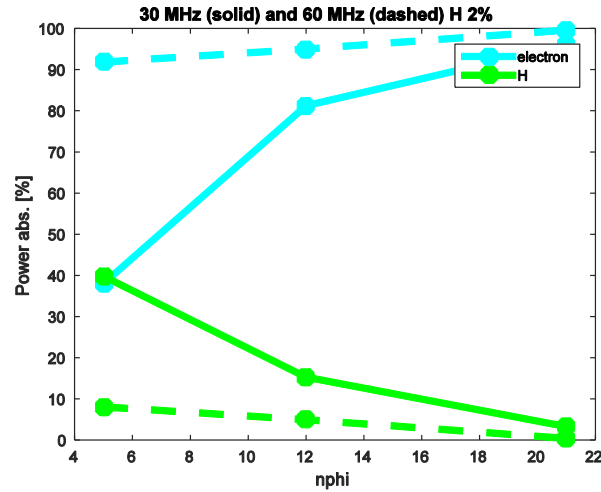
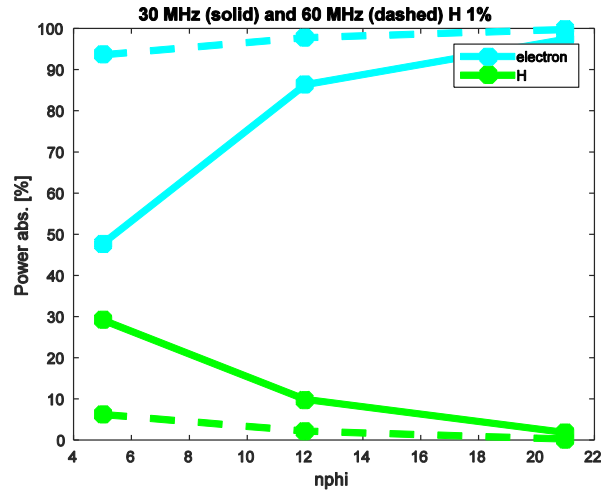


Comparison between $f = 30$ and 60 MHz

H 1%, 2%, 5% and 10%

NO NBI

Power abs. vs. nphi (f = 30MHz solid, f = 60MHz dashed curves)



- Dominant electron abs. for all nphi for 60 MHz case
- Significant H abs. for for nphi = -5 and -12 for 30MHz case

Conclusions for $f = 30$ and 60 MHz without NBI

- Large electron damping for all n_{phi} for 60 MHz
- No significant differences between $f = 30$ and 60 MHz cases for $n_{\text{phi}} = -21$
- Dominant H absorption for $n_{\text{phi}} = -5$ and for 30 MHz case
- Dominant electron absorption for $n_{\text{phi}} = -12$ and for 30 MHz case & H concentration $< 5\%$

Future steps

- Additional AORSA simulations for NSTX-U scenarios
 - concentration scan
 - B scan
 - H concentration scan
 - Temperature and density “scan”
 - H plasma
 - w/ & w/o NBI
 - frequency = 15, 30, and 60 MHz
- AORSA runs for NSTX cases (one or two cases)
 - Temperature and density “scan”
 - H concentration scan
 - w/ & w/o NBI
- Repeat simulations above with AORSA+CQL3D
 - In case of H & NBI, consider both non-Maxwellian species